<u>L2</u>	5838120.pn.	2	1.2	
	plasma and source and beam and (discharge adj cavity) and cathode and	_	<u></u>	
<u>L1</u>	magnetron and discharge and magnets and (magnetic adj field) and (null near2 region) and (introduc\$3 near3 gas)	2	<u>L1</u>	

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END OF SEARCH HISTORY

Freeform Search

Freeform Search

-	
	US Pre-Grant Publication Full-Text Database
	US Patents Full-Text Database
	US OCR Full-Text Database
Database:	EPO Abstracts Database
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	Derwent World Patents Index
	IBM Technical Disclosure Bulletins
Term:	(magnetron adj discharge) and cavity and nozzle
Display:	10 Documents in Display Format: TI Starting with Number 1
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Search History

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Set Name side by side	Query	Hit Count	Set Name result set
DB = 1	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD; PLUR=YES; OP=OR		
<u>L13</u>	(magnetron adj discharge) and cavity and nozzle	. 5	<u>L13</u>
<u>L12</u>	L8 and discharge and cavity and aperture and nozzle	19	<u>L12</u>
<u>L11</u>	L8 and (discharge adj cavity) and aperture and nozzle	5	<u>L11</u>
<u>L10</u>	L9 and null	9	<u>L10</u>
<u>L9</u>	L8 and nozzle	. 45	<u>L9</u>
<u>L8</u>	(beam adj source) and plasma and magnets and (magnetic adj field) and cavity	232	<u>L8</u>
<u>L7</u>	L5 and discharge	. 7	<u>L7</u>
<u>L6</u>	L5 and magnetron	2	<u>L6</u>
<u>L5</u>	L4 and gas and (chamber or cavity)	22	<u>L5</u>
<u>L4</u>	beam and (magnetic adj field) and (null near3 region) and magnets and nozzle	22	<u>L4</u>
<u>L3</u>	PECVD and cavity and discharge and nozzle and magnets and (magnetic adj field) and (ioniz\$4 adj gas)	9	<u>L3</u>
<u>L2</u>	5838120.pn.	2	<u>L2</u>
<u>L1</u>	plasma and source and beam and (discharge adj cavity) and cathode and magnetron and discharge and magnets and (magnetic adj field) and (null near2	2	<u>L1</u>

Freeform Search

Database	US Pre-Grant Publication Full-Text Database US Patents Full-Text Database US OCR Full-Text Database EPO Abstracts Database JPO Abstracts Database Derwent World Patents Index IBM Technical Disclosure Bulletins
Term:	L8 and discharge and cavity and aperture and nozzle
Display: Generate:	Documents in <u>Display Format</u> : Starting with Number 1 C Hit List • Hit Count C Side by Side C Image
	Search Clear Interrupt
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DATE: Friday, December 29, 2006 Purge Queries Printable Copy Create Case

Set Name side by side	Query	Hit Count	Set Name result set
DB = 1	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD; PLUR=YES; OP=OR		
<u>L12</u>	L8 and discharge and cavity and aperture and nozzle	19	<u>L12</u>
<u>L11</u>	L8 and (discharge adj cavity) and aperture and nozzle	5	<u>L11</u>
<u>L10</u>	L9 and null	9	<u>L10</u>
<u>L9</u>	L8 and nozzle	45	<u>L9</u>
<u>L8</u>	(beam adj source) and plasma and magnets and (magnetic adj field) and cavity	232	<u>L8</u>
<u>L7</u>	L5 and discharge	7	<u>L7</u>
<u>L6</u>	L5 and magnetron	2	<u>L6</u>
<u>L5</u>	L4 and gas and (chamber or cavity)	22	<u>L5</u>
<u>L4</u>	beam and (magnetic adj field) and (null near3 region) and magnets and nozzle	22	<u>L4</u>
<u>L3</u>	PECVD and cavity and discharge and nozzle and magnets and (magnetic adj field) and (ioniz\$4 adj gas)	9	<u>L3</u>
<u>L2</u>	5838120.pn.	2	<u>L2</u>
<u>L1</u>	plasma and source and beam and (discharge adj cavity) and cathode and magnetron and discharge and magnets and (magnetic adj field) and (null near2 region) and (introduc\$3 near3 gas)	2	<u>L1</u>



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